

(12) **United States Design Patent**
Shiue

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(54) **DIVING MASK**

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(**) Term: **14 Years**

(21) Appl. No.: **29/300,533**

(22) Filed: **Apr. 7, 2008**

(51) **LOC (9) Cl.** **16-06**

(52) **U.S. Cl.** **D16/312; D16/303**

(58) **Field of Classification Search** D16/101,
D16/300, 301, 302, 303, 304, 305, 306, 307,
D16/308, 309, 310, 311, 312, 314, 315, 316,
D16/317, 318, 319, 320, 321, 322, 323, 324,
D16/325, 326, 327, 328, 329, 330; D29/109,
D29/110; D24/110.2; 351/41, 44, 51, 52,
351/61, 62, 63, 83, 86, 92, 103, 104, 105,
351/106, 107, 108, 109, 110, 111, 114, 117,
351/119, 121, 123, 124, 128, 130, 131, 132,
351/136, 137, 138, 139, 153, 158; 2/424,
2/426, 427, 428, 429, 430, 431, 432, 436,
2/437, 447, 448, 449, 453; D21/190
See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

D352,950 S * 11/1994 Rasocha D16/303

D371,566 S * 7/1996 Kolada et al. D16/311
D385,574 S * 10/1997 Fireman D16/311
D450,833 S * 11/2001 Olivieri D24/110.2
D522,562 S * 6/2006 Godoy D16/311
D551,280 S * 9/2007 Li D16/312

* cited by examiner

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(57) **CLAIM**

The ornamental design for a diving mask, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a diving mask showing the new design;

FIG. 2 is a top view thereof;

FIG. 3 is a front view thereof;

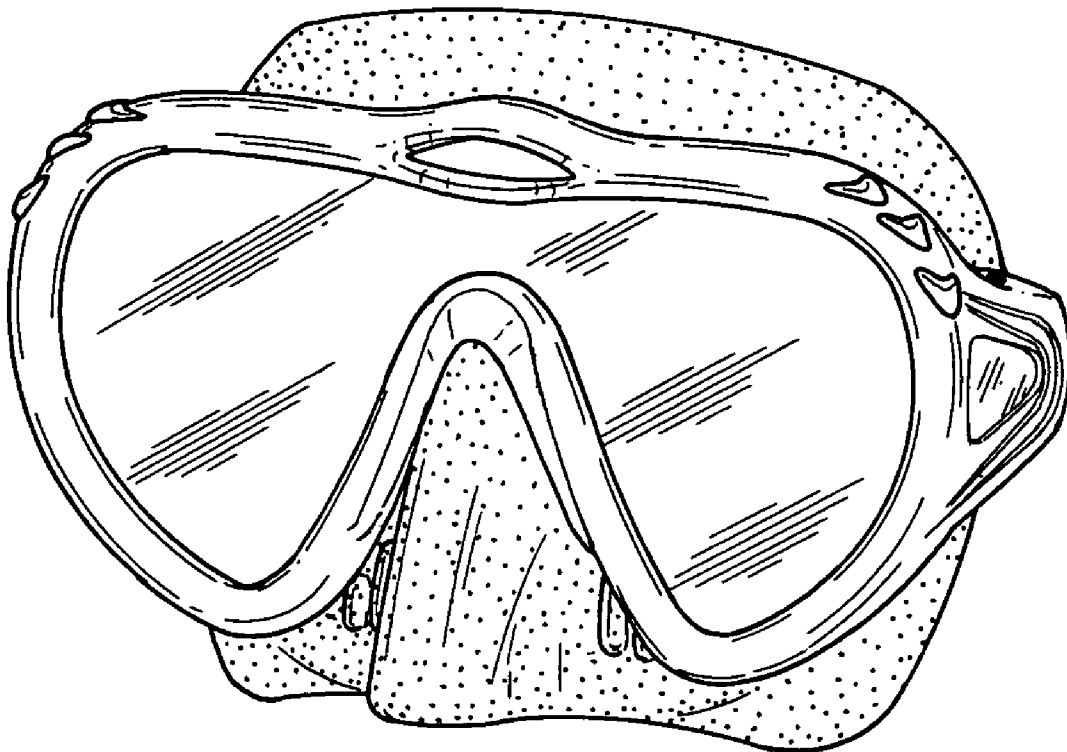
FIG. 4 is a bottom view thereof;

FIG. 5 is a rear view thereof;

FIG. 6 is a left side view thereof; and,

FIG. 7 is a right side view thereof.

1 Claim, 3 Drawing Sheets



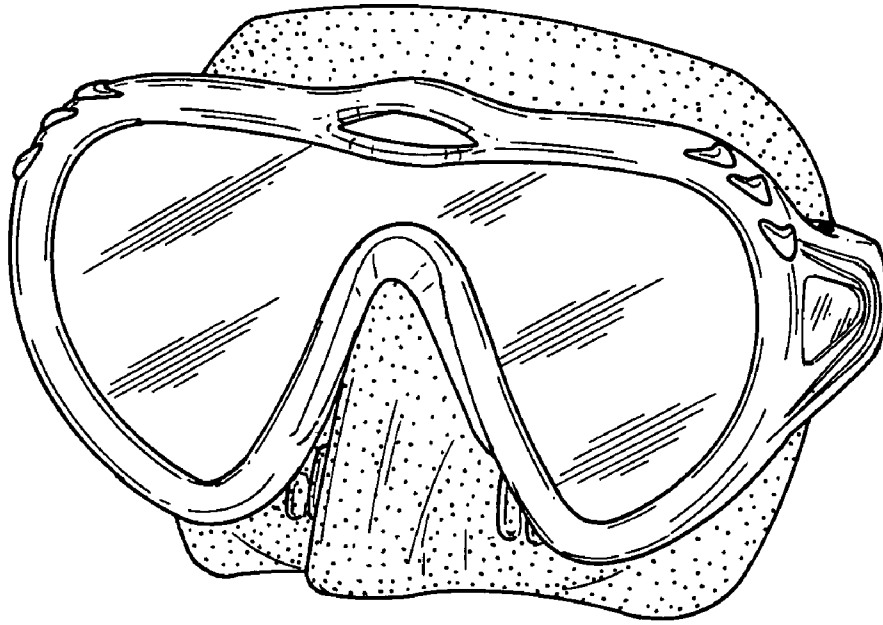


FIG. 1

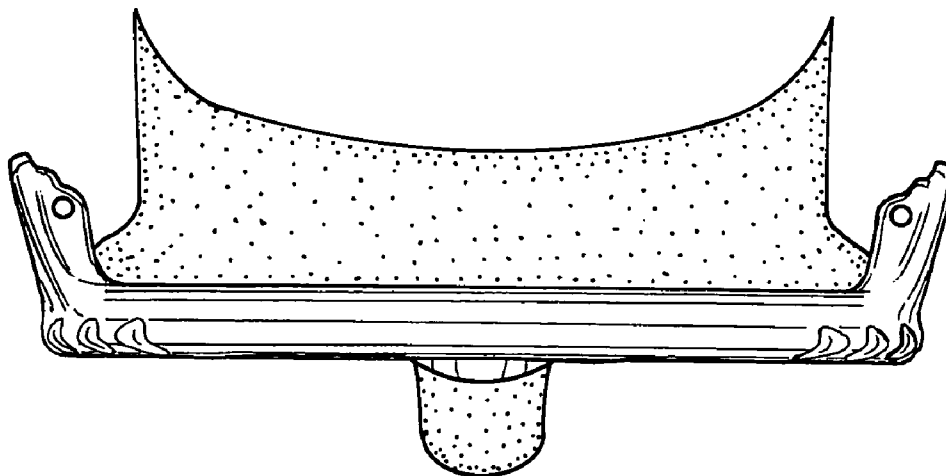


FIG. 2

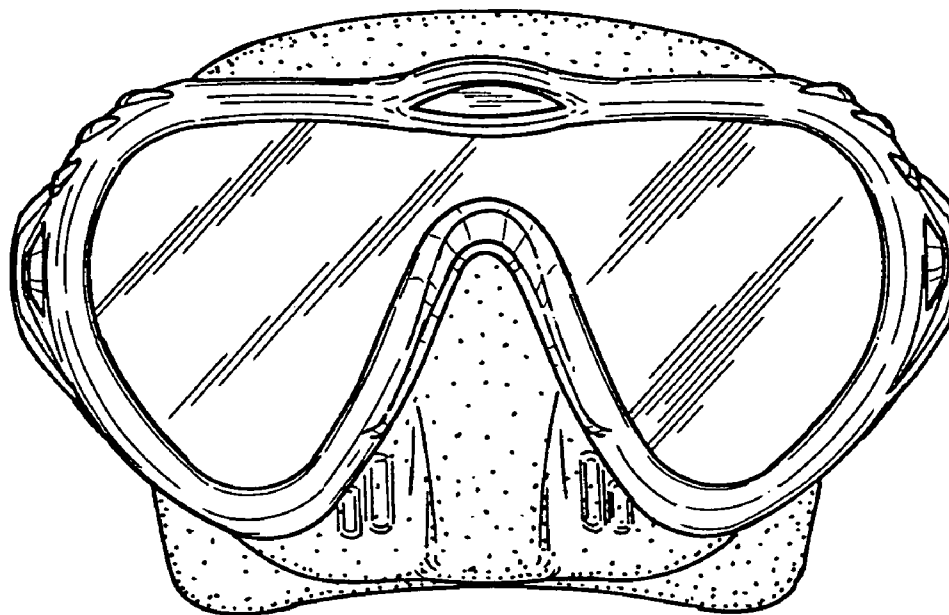


FIG. 3

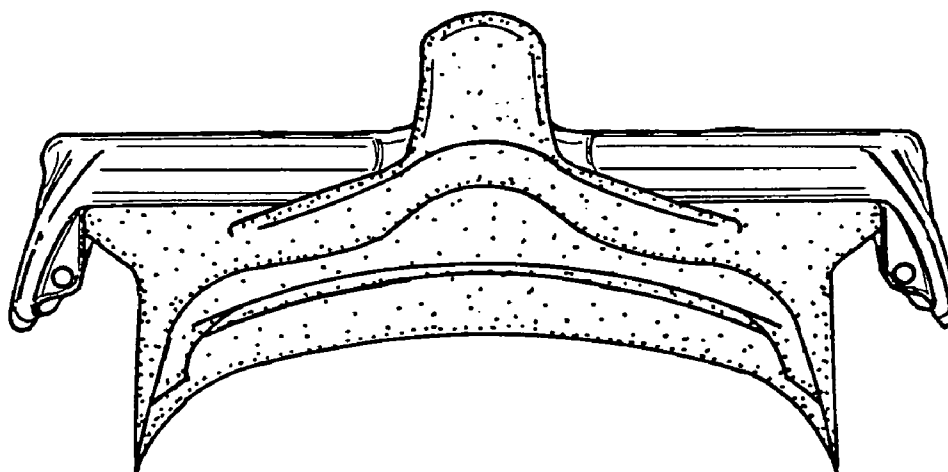


FIG. 4

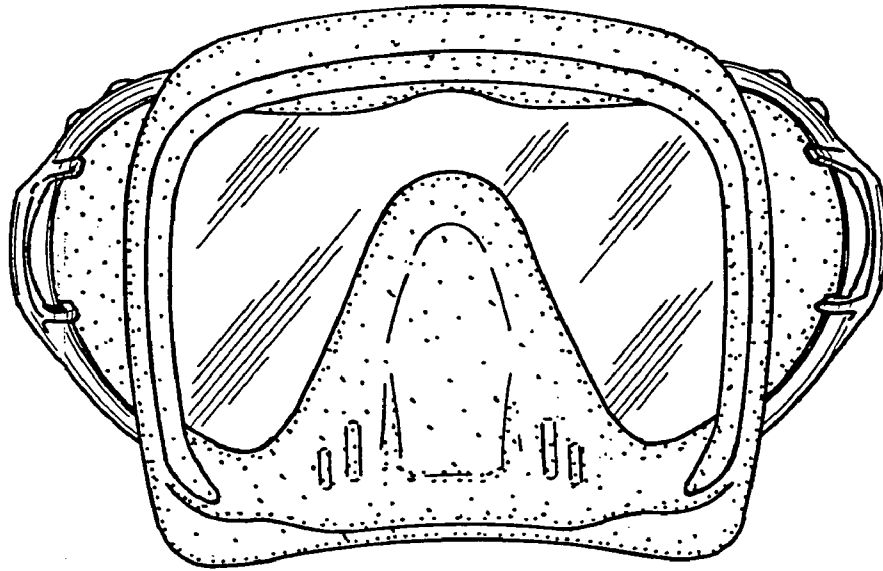


FIG. 5

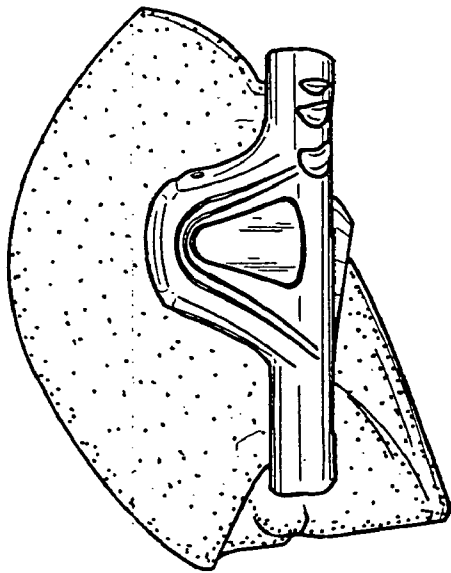


FIG. 6

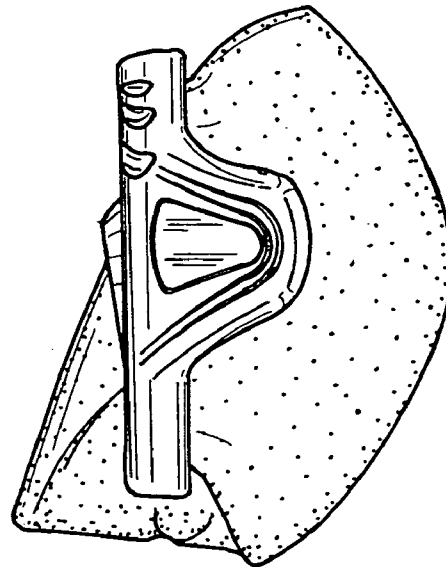


FIG. 7